

L Number	Hits	Search Text	DB	Time stamp
2	48665	photoresist	USPAT; US-PGPUB	2002/01/15 14:26
1	10	photorsist	USPAT; US-PGPUB	2002/01/15 14:27
3	48665	photorsist photoresist	USPAT; US-PGPUB	2002/01/15 14:27
4	46236	((photorsist photoresist) and (remov\$3 etch\$3 dehas\$3))	USPAT; US-PGPUB	2002/01/15 14:29
5	223	((photorsist photoresist) and (remov\$3 etch\$3 dehas\$3)) and ((remov\$3 etch\$3) with photoresist) with (("H.sub.2" adj "O") H2O (NH3 ("N" adj "H.sub.3") N2 ("N.sub.2"))))	USPAT; US-PGPUB	2002/01/15 15:58
6	344	((remov\$3 etch\$3) with photoresist) with (ammonia ("NH.sub.3") NH3 ("N" adj "H.sub.3"))	USPAT; US-PGPUB	2002/01/15 16:52
7	150	((remov\$3 etch\$3) with photoresist) with (ammonia ("NH.sub.3") NH3 ("N" adj "H.sub.3"))	EPO; JPO; DERWENT; IBM TDB	2002/01/15 17:20
8	158	((remov\$3 etch\$3) with photoresist) with (nitrogen N2 "N.sub.2")	EPO; JPO; DERWENT; IBM TDB	2002/01/15 17:21
9	284	((remov\$3 etch\$3) with photoresist) with (nitrogen N2 "N.sub.2")	USPAT	2002/01/15 17:22
-	986	((remov\$3 etch\$3) same photoresist) same (("H.sub.2" adj "O") H2O (NH3 ("N" adj "H.sub.3") N2 ("N.sub.2"))))	USPAT; US-PGPUB	2002/01/12 16:47
-	572	((remov\$3 etch\$3) same photoresist) same (("H.sub.2" adj "O") H2O (NH3 ("N" adj "H.sub.3") N2 ("N.sub.2")))) ) and electrode	USPAT; US-PGPUB	2002/01/12 15:29
-	23	((remov\$3 etch\$3) same photoresist) same (("H.sub.2" adj "O") H2O (NH3 ("N" adj "H.sub.3") N2 ("N.sub.2")))) ) and electrode) and ((Ru ruthneium) RuO RuO2)	USPAT; US-PGPUB	2002/01/12 16:42
-	173	((remov\$3 etch\$3) same photoresist) same (("H.sub.2" adj "O") H2O (NH3 ("N" adj "H.sub.3") N2 ("N.sub.2"))))	EPO; JPO; DERWENT; IBM TDB	2002/01/12 16:41
-	1	((remov\$3 etch\$3) same photoresist) same (("H.sub.2" adj "O") H2O (NH3 ("N" adj "H.sub.3") N2 ("N.sub.2")))) ) and ((Ru ruthneium) RuO RuO2)	EPO; JPO; DERWENT; IBM TDB	2002/01/12 16:43
-	3	etch\$3 same (nonreactive non?reactive (non adj2 reactive)) same ((Ru ruthneium) RuO RuO2)	USPAT; US-PGPUB	2002/01/12 16:46
-	0	etch\$3 same (nonreactive non?reactive (non adj2 reactive)) same ((Ru ruthneium) RuO RuO2)	EPO; JPO; DERWENT; IBM TDB	2002/01/12 16:47
-	223	((remov\$3 etch\$3) with photoresist) with (("H.sub.2" adj "O") H2O (NH3 ("N" adj "H.sub.3") N2 ("N.sub.2"))))	USPAT; US-PGPUB	2002/01/12 17:07
-	244	((remov\$3 etch\$3) with photoresist) with (("H.sub.2" adj "O") H2O (NH3 ("N" adj "H.sub.3") ("NH.sub.3")) N2 ("N.sub.2"))))	USPAT; US-PGPUB	2002/01/12 17:09